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AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the

application:

LISTING OF CLAIMS:

1. (currently amended): An anisotropic material comprising an alternating-line

pattern and a layer of at least one functional compound selected from the group consisting of a

semiconductor compound, an electrically conductive compound, a photochromic compound and

a thermochromic compound, formed on a surface of the alternating-line pattern, wherein one

type of lines in the alternating-line pattern surface comprises a fluorine-containing compound,

the fluorine-containing compound is at least one fluorine-containing organic silane compound

the indomie-containing compound is at least one recome containing organic street

selected from the group consisting of:

(a) a fluorine compound of the formula:

Rf-A-SiX3, or

Rf-O-A-SiX3.

wherein Rf is a branched perfluoroalkyl group having 3 to 5 carbon atoms,

A is an alkylene group having 1 to 4 carbon atoms,

Aa -SO₂N(R²¹)R²²- group provided that R²¹ is an alkyl group having 1 to 4 carbon atoms,

and R22 is an alkylene group having 1 to 4 carbon atoms or a -CH2CH(OH)CH2- group, and

X is a hydrogen atom, a halogen atom, or OC_nH_{2n+1} wherein n is 1 to 4,

(b) a fluorine compound having a perfluoropolyether group of the formula:

PFPE-A-SiX₃.

wherein PFPE is a perfluoropolyether group,

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AMENDMENT UNDER 37 C.F.R. § 1.111

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A is an alkylene group having 1 to 4 carbon atoms,

a $-SO_2N(R^{21})R^{22}$ - group provided that R^{21} is an alkyl group having 1 to 4 carbon atoms, and R^{22} is an alkylene group having 1 to 4 carbon atoms or a $-CH_2CH(OH)CH_2$ - group, and

X is a hydrogen atom, a halogen atom, or OC_nH_{2n+1} wherein n is 1 to 4,

(c) a fluorine compound having a polymer structure of the formula:

Polymer-D-SiX₃,

wherein Polymer represents a polymer structure group obtained by polymerizing a monomer which has a fluoroalkyl group having 5 or less carbon atoms, and perfluoroalkyl group-containing monomer represented by the general formula:

Rf-A-OC(=O)CR3=CH2

wherein Rf is a straight-chain or branched perfluoroalkyl group having 1 to 5 earbon atoms.

 R^3 is a hydrogen atom, an F atom, a Cl atom, a CF2 group, a CF2H group, a CFH2 group or a methyl group, and

A is an alkylene group having 1-to 4-carbon atoms, a $SO_2N(R^{2+})R^{22}$ group provided that R^{24} is an alkylene group having 1-to 4-carbon atoms, and R^{24} is an alkylene group having 1-to 4-carbon atoms or a $-CH_2CH(OH)CH_2$ -group, D represents $-S(CH_2)_2OCONH(CH_2)_4$ - $-S(CH_2)_pOCONH(CH_2)_4$ - wherein p and q are 1-to 4, or $-CH_2CH_2$ -, and

X represents a hydrogen atom, a halogen atom, or OC_nH_{2n+1} wherein n is 1 to 4, and

(d) a fluorine compound having a linking group of the formula:

Rf-A-Z-A'-SiX3

wherein Rf represents a perfluoroalkyl group having 5 or less carbon atoms,

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A and A' represent an alkylene group having 1 to 4 carbon atoms, a ${}^{2}N(R^{21})R^{22}$ -group provided that R^{21} is an alkyl group having 1 to 4 carbon atoms, and R^{22} is an alkylene group having 1 to 4 carbon atoms or a ${}^{2}R^{21}R^{22}$ -group,

Z is a urethane group, an ester group, an ether group or an amide group, and X is a hydrogen atom, a halogen atom, or OC_nH_{2n+1} wherein n is 1 to 4, or the fluorine-containing compound is at least one selected from the group consisting of:

(e) an incompletely-condensed silsesquioxane which has a perfluoroalkyl group having 5 or less carbon atoms, represented by the general formula:

wherein R and R' represent Rf, Rf-A, an alkyl group having 1 to 22 carbon atoms, or a derivative of an alkyl group having 1 to 22 carbon atoms provided that at least one of R and R' is Rf or Rf-A wherein Rf represents a perfluoroalkyl group having 5 or less carbon atoms, and A represents an alkylene group having 1 to 4 carbon atoms, a -SO₂N(R²¹)R²²- group provided that R²¹ is an alkyl group having 1 to 4 carbon atoms, and R²² is an alkylene group having 1 to 4 carbon atoms or a -CH₂CH(OH)CH₂- group, and 1 and m represent such a number that a molecular weight of the incompletely-condensed silsesquioxane is within a range from 500 to 100000, and

(f) a completely-condensed silsesquioxane which has a silane group and a perfluoroalkyl group having 5 or less carbon atoms, represented by the formula:

$$[\text{R-SiO}_{3/2}]_l[\text{R'-SiO}_{3/2}]_m$$

wherein R represents Rf, Rf-A, an alkyl group having 1 to 22 carbon atoms, or a derivative of an alkyl group having 1 to 22 carbon atoms provided that at least one of R is Rf or Rf-A wherein Rf represents a perfluoroalkyl group having 5 or less carbon atoms, A represents

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an alkylene group having 1 to 4 carbon atoms, a 2 -SO₂N(R²¹)R²²- group provided that R²¹ is an alkyle group having 1 to 4 carbon atoms, and R²² is an alkylene group having 1 to 4 carbon atoms or a 2 -CH₂CH(OH)CH₂- group, R' represents an organic group containing SiX₃, wherein X is a hydrogen atom, a halogen atom or OC_nH_{2n+1} where n=1 to 4 and 1 and m represent such a number that a molecular weight of the completely-condensed silesequioxane is within a range from 500 to 100000.

- (previously presented): The anisotropic material according to claim 1, wherein a
 difference between surface free energy of the type of lines comprising the fluorine compound
 and surface free energy of the other type of lines is at least 5 mJ/m².
- 3. (original): The anisotropic material according to claim 1, wherein the alternating-line pattern has a line width of 0.5 to $100 \, \mu m$.
- (original): The anisotropic material according to claim 1, wherein the alternatingline pattern has unevenness of not more than 10 nm.
- 5. (original): The anisotropic material according to claim 1, wherein the shape of droplets is distorted when 2 μ L of ethanol is gently dropped from above the alternating-line pattern, and the degree of distortion is at least 1.1 in terms of a ratio L/W of the length in a major axis (L) to the length in a minor axis (W) of droplets.
 - 6. (canceled).
- 7. (withdrawn-currently amended): A method for producing an anisotropic material comprising an alternating-line pattern and a layer of at least one functional compound selected from the group consisting of a semiconductor compound, an electrically conductive compound, a photochromic compound and a thermochromic compound, formed on a surface of the alternating-line pattern, wherein one type of lines in the alternating-line pattern surface

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comprises a fluorine-containing compound, the fluorine-containing compound is at least one fluorine-containing organic silane compound, selected from the group consisting of:

(a) a fluorine compound of the formula:

Rf-A-SiX3, or

Rf-O-A-SiX3,

wherein Rf is a branched perfluoroalkyl group having 3 to 5 carbon atoms,

A is an alkylene group having 1 to 4 carbon atoms,

 $A_{\underline{a}}$ -SO₂N(R²¹)R²²- group provided that R²¹ is an alkyl group having 1 to 4 carbon atoms, and R²² is an alkylene group having 1 to 4 carbon atoms or a -CH₂CH(OH)CH₂- group, and

X is a hydrogen atom, a halogen atom, or OC_nH_{2n+1} wherein n is 1 to 4,

(b) a fluorine compound having a perfluoropolyether group of the formula:

PFPE-A-SiX₃,

wherein PFPE is a perfluoropolyether group,

A is an alkylene group having 1 to 4 carbon atoms,

a -SO₂N(R²¹)R²²- group provided that R²¹ is an alkyl group having 1 to 4 carbon atoms, and R²² is an alkylene group having 1 to 4 carbon atoms or a -CH₂CH(OH)CH₂- group, and

X is a hydrogen atom, a halogen atom, or OC_nH_{2n+1} wherein n is 1 to 4,

(c) a fluorine compound having a polymer structure of the formula:

Polymer-D-SiX₃,

wherein Polymer represents a polymer structure group obtained by polymerizing a monomer which has a fluoroalkyl group having 5 or less carbon atoms, and

perfluoroalky! group-containing monomer represented by the general formula:

Rf-A-OC(=O)CR3=CH2

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wherein Rf is a straight-chain or branched perfluoroalkyl group having 1 to 5 carbon atoms.

R³ is a hydrogen atom, an F atom, a Cl atom, a CF₂ group, a CF₂H group, a CFH₂ group or a methyl group, and

A is an alkylene group having 1 to 4 carbon atoms, a $SO_2N(R^{24})R^{22}$ group provided that R^{24} is an alkylene group having 1 to 4 carbon atoms, and R^{24} is an alkylene group having 1 to 4 carbon atoms or a $-CH_2CH(OH)CH_2$ -group; D represents $-S(CH_2)_2OCONH(CH_2)_4$ - $-S(CH_2)_2OCONH(CH_2)_4$ wherein p and q are 1 to 4, or $-CH_2CH_2$ -, and

X represents a hydrogen atom, a halogen atom, or OC_nH_{2n+1} wherein n is 1 to 4, and

(d) a fluorine compound-having a linking group of the formula:

Rf-A-Z-A'-SiX3

wherein Rf represents a perfluoroalkyl group having 5 or less carbon atoms,

A and A' represent an alkylene group having 1 to 4 carbon atoms, a -SO₂N(R²¹)R²²-group provided that R²¹ is an alkyl group having 1 to 4 carbon atoms, and R²² is an alkylene group having 1 to 4 carbon atoms or a -CH₂CH(OH)CH₂-group,

(e) an incompletely-condensed silsesquioxane which has a perfluoroalkyl group having 5 or less carbon atoms, represented by the general formula:

 $[R-Si(OH)O_{2/2}]_{I}[R'-SiO_{3/2}]_{m}$

wherein R and R' represent Rf, Rf-A, an alkyl group having 1 to 22 carbon atoms, or a derivative of an alkyl group having 1 to 22 carbon atoms provided that at least one of R and R' is

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Rf or Rf-A wherein Rf represents a perfluoroalkyl group having 5 or less carbon atoms, and A represents an alkylene group having 1 to 4 carbon atoms, a $-SO_2N(R^{21})R^{22}$ - group provided that R^{21} is an alkylene group having 1 to 4 carbon atoms, and R^{22} is an alkylene group having 1 to 4 carbon atoms or a $-CH_2CH(OH)CH_2$ - group, and I and m represent such a number that a molecular weight of the incompletely-condensed silsesquioxane is within a range from 500 to 100000, and

(f) a completely-condensed silsesquioxane which has a silane group and a perfluoroalkyl group having 5 or less carbon atoms, represented by the formula:

wherein R represents Rf, Rf-A, an alkyl group having 1 to 22 carbon atoms, or a derivative of an alkyl group having 1 to 22 carbon atoms provided that at least one of R is Rf or Rf-A wherein Rf represents a perfluoroalkyl group having 5 or less carbon atoms, A represents an alkylene group having 1 to 4 carbon atoms, a -SO₂N(R²¹)R²²- group provided that R²¹ is an alkyl group having 1 to 4 carbon atoms, and R²² is an alkylene group having 1 to 4 carbon atoms or a -CH₂CH(OH)CH₂- group, R' represents an organic group containing SiX₃, wherein X is a hydrogen atom, a halogen atom or OC_nH_{2n+1} where n=1 to 4 and 1 and m represent such a number that a molecular weight of the completely-condensed silsesquioxane is within a range from 500 to 100000,

which method comprises applying a solution of at least one functional compound selected from the group consisting of a semiconductor compound, an electrically conductive compound, a photochromic compound and a thermochromic compound on the surface of an alternating-line pattern, one type of lines of which comprises a fluorine-containing compound.

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8. (withdrawn): The method according to claim 7, wherein a liquid which dissolves the functional compound is a solvent having a surface tension of not more than 30 mN/m.

- (withdrawn): A method for producing a functional material, comprising using, as a template, a pattern surface composed of plural regions each having different surface free energy, characterized in that:
 - (1) at least one region of the pattern surface is treated with a fluorine compound, and
- (2) the method comprises applying a functional compound solution on the pattern surface and removing a solvent.
 - 10. (canceled).
 - 11. (withdrawn): A functional material produced by the method according to claim 9.
- 12. (withdrawn): A method for producing a functional material, which comprises applying a functional compound to a pattern surface having at least one region surface-treated with a fluorine compound.
- 13. (withdrawn): The method according to claim 12, wherein the fluorine compound comprises a fluorine compound having the following structure:
- (a) a fluorine compound which has a branched fluoroalkyl group having 5 or less carbon atoms,
 - (b) a fluorine compound having a perfluoropolyether group,
- (c) a fluorine compound having a polymer structure obtained by polymerizing a monomer which has a fluoroalkyl group having 5 or less carbon atoms,
- (d) a fluorine compound having a linking group which is any one of an urethane group, an ester group, an ether group and an amide group, existing between a fluoroalkyl group having 5 or less carbon atoms and a functional group,

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(e) an incompletely-condensed silsesquioxane which has a fluoroalkyl group having 5 or less carbon atoms, and

- (f) a completely-condensed silsesquioxane which has a silane group and a fluoroalkyl group having 5 or less carbon atoms.
- (withdrawn): A functional material produced by the method according to claim 12.
- 15. (previously presented): An anisotropic material according to claim 1, wherein both lines of the alternating-line pattern are made of a monomolecular film.
- 16. (previously presented): The anisotropic material according to claim 1, wherein the layer of the at least one functional compound has a thickness of from 0.1 nm to 100 μm .
- 17. (previously presented): The anisotropic material according to claim 1, wherein the fluorine-containing compound comprises compound (a).
 - 18. (canceled).